

ANTISTATIC FILM AND PROCESS FOR ITS MANUFACTURE

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ABSTRACT OF THE DISCLOSURE

An antistatic film with a surface resistivity of
10¹³ Ω/□, comprising a metal oxide and conductive
10 ultrafine particle mixed layer formed on the surface of a
film, and a process for manufacture of the antistatic
film which comprises coating the surface of a self-
supporting film, obtained by casting and drying a
solution of a heat-resistant resin precursor, with a
15 mixture obtained by uniformly combining a metal compound
which converts to a metal oxide upon heating, conductive
ultrafine particles and a solvent, and then heating it to
dryness, removing the solvent and cyclizing the heat-
resistant resin precursor. The film exhibits improved
20 antistatic retention with no reduction in its original
mechanical properties and formed without the use of
special equipment such as a sputtering apparatus, as well
as a process for its manufacture.